

CHI performance Improvement

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> NSTX 5YR Planning Meeting Integrated Scenario Development Princeton Plasma Physics Laboratory February 16, 2007

Outline

- Increase the current of Transient CHI plasmas
 - Couple to induction
 - Produce a reference startup plasma for other XPs
 - Couple to RF and NBI (work with the RF group)
- CHI startup with outer PF
- Insulator and voltage design improvements
- Edge current drive
 - Relaxation current drive

Increase the current of Transient CHI plasmas

- Results indicate 300kA should be possible in NSTX at 2kV
 - Planned for 2008



• Improvements to NSTX voltage capability in addition to inclusion of some vertical field should allow extension to 500kA (Work in progress)

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HIT-II data: R. Raman et al., Nucl. Fusion, 45, L15-L19 (2005), Phys. Plasmas 11 (2004) 2565

Couple to Induction (as demonstrated on HIT-II)

Results from HIT-II show nearly all CHI-produced closed flux current is retained in the subsequent inductive ramp



Both discharges have identical loop voltage programming Raman_ISD_16Feb07 *R. Raman, T.R. Jarboe, R.G. O'Neill, et al., NF* **45** (2005) L15-L19 Produce reference discharges (as demonstrated on HIT-II) Use 200kW ECH for further V-S savings and to couple to RF



Improves performance and saves volt-seconds 5

Pre-charge using vertical field (as demonstrated on HIT-II)

HIT-II data





CHI discharges in HIT-II can be started when the CS is in the process of being pre-charged



- Important for a burning plasma reactor that may contain a small central transformer
 - R. Raman et al., Phys. Plasmas **11** (2004) 2565 Expt. Suggested by M. Ono

HIT-II data

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Voltage increase to 4kV possible without exceeding 2kV IV to TF limits

- •Inner and outer vessel both grounded
- •Portions of inner and outer divertor plates insulated
 - -Simpler non-vacuum insulator
 - -Similar to ring electrode used in DIII-D to drive 30kA
 - electrode current

•Lithium can help pump the region below the plates



HIT-II data

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CHI Edge current successfully driven in HIT-II discharges but current profile not diagnosed



HIT-II data

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R. Raman et al., Phys. Plasmas **11** (2004) 2565 ⁹

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FIG. 3. Injector voltage, injector λ , tokamak λ , injector current, and plasma current for two levels of CHI edge drive, $\lambda_{inj} < \lambda_{tok}$ (left) and $\lambda_{inj} > \lambda_{tok}$ (right). For each case, a reference Ohmic only discharge is shown with a dashed line.

HIT-II data Use results from Edge current drive studies for higher current relaxation current drive studies

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D. Mueller et al., Phys. Plasmas **12** (2005) 070702¹⁰

Demonstration of high current capability in NSTX opens up new exciting possibilities for CHI in NSTX

> •Higher levels of Transient CHI startup current - Coupling to induction

- Reference startup plasma for other XPs
- Coupling to RF and NBI RF group)

•CHI startup with some outer PF

•Insulator and voltage design improvements to extend CHI capability and simplification of insulator design

•Edge current drive for edge current profile control - Relaxation current drive a possibility